

# Special Topics on Basic EECS I

## VLSI Devices

### Lecture 8

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# Homework#2

- Sheet resistivity

- Assume the following electron distribution,

$$n(z) = n_s \exp\left(-\frac{z}{\Delta}\right),$$

where the vertical coordinate,  $z$ , starts at 0.

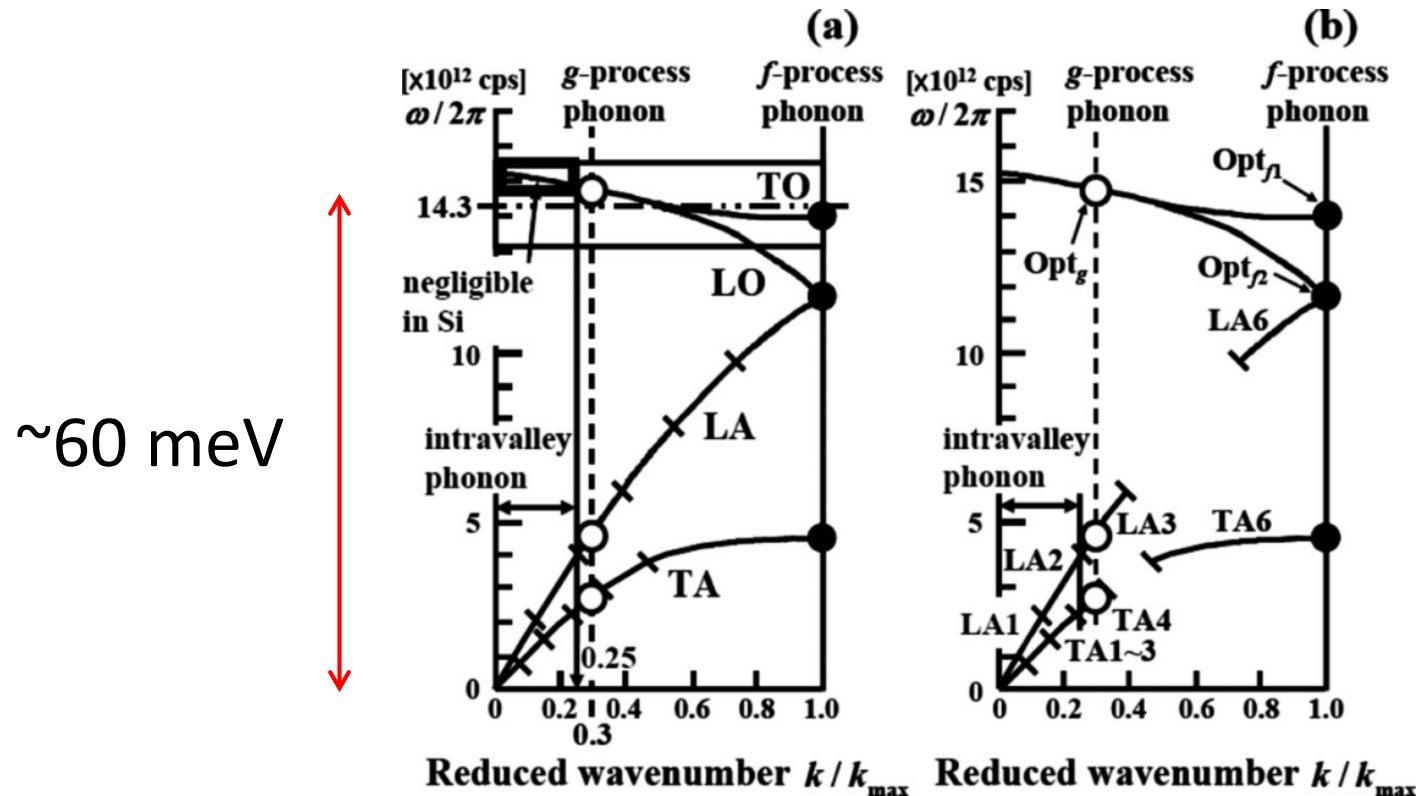
- Also assume a constant electron mobility,  $\mu_n$ .
  - (Neglect holes.)
  - Calculate the sheet resistivity, which satisfies  $R = \frac{L}{W} \rho_{sh}$ .

## Example 2-2 of Hu's book

- Hole mobility,  $\mu_p = 470 \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$ 
  - When the electric field is  $10^3 \text{ V cm}^{-1}$ , the drift velocity is  $4.7 \times 10^5 \text{ cm s}^{-1}$ .
  - Momentum relaxation time (with  $m_p = 0.39 m_0$ ) is 0.1 psec.

# Phonon scattering

- Various phonon modes
  - Acoustic phonon : Low energy
  - Optical phonon : High energy, often treated as dispersion-less



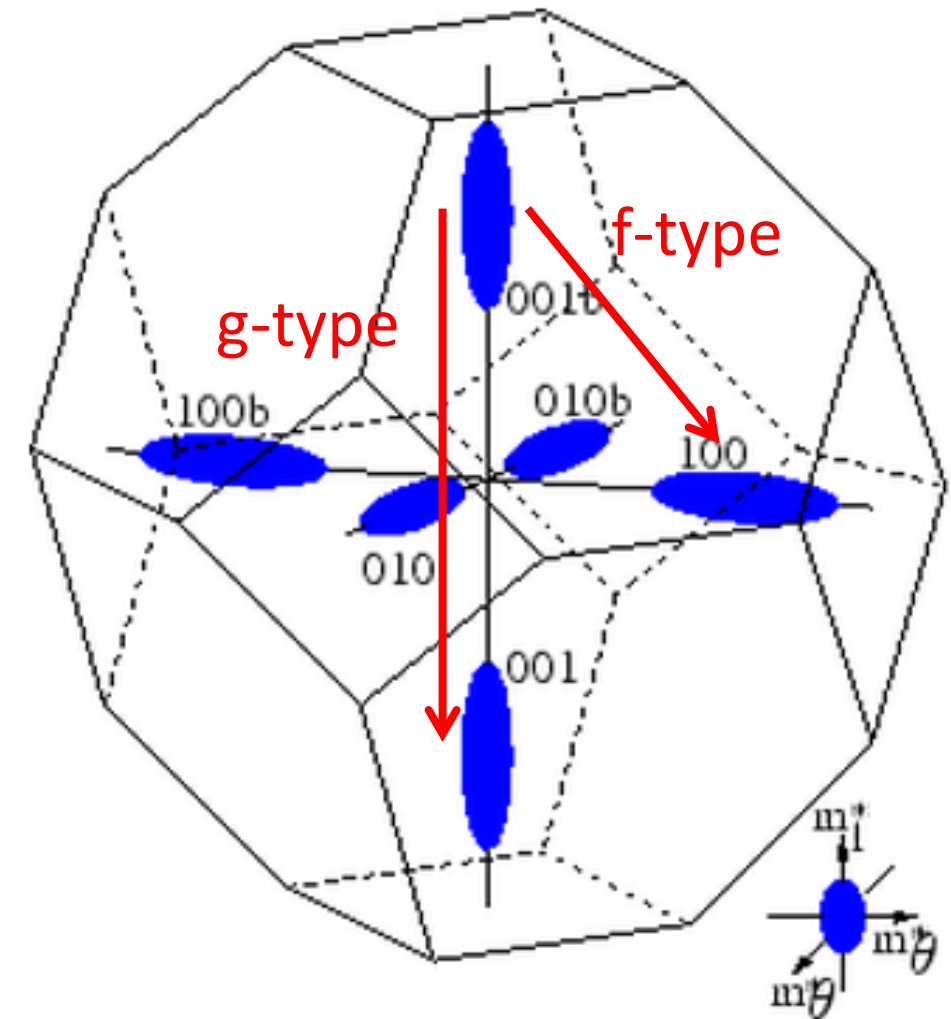
“Selection rule” matters.  
Intravalley / f-process / g-process

# Typical parameters

- Various phonon modes
  - Acoustic phonon : Low energy

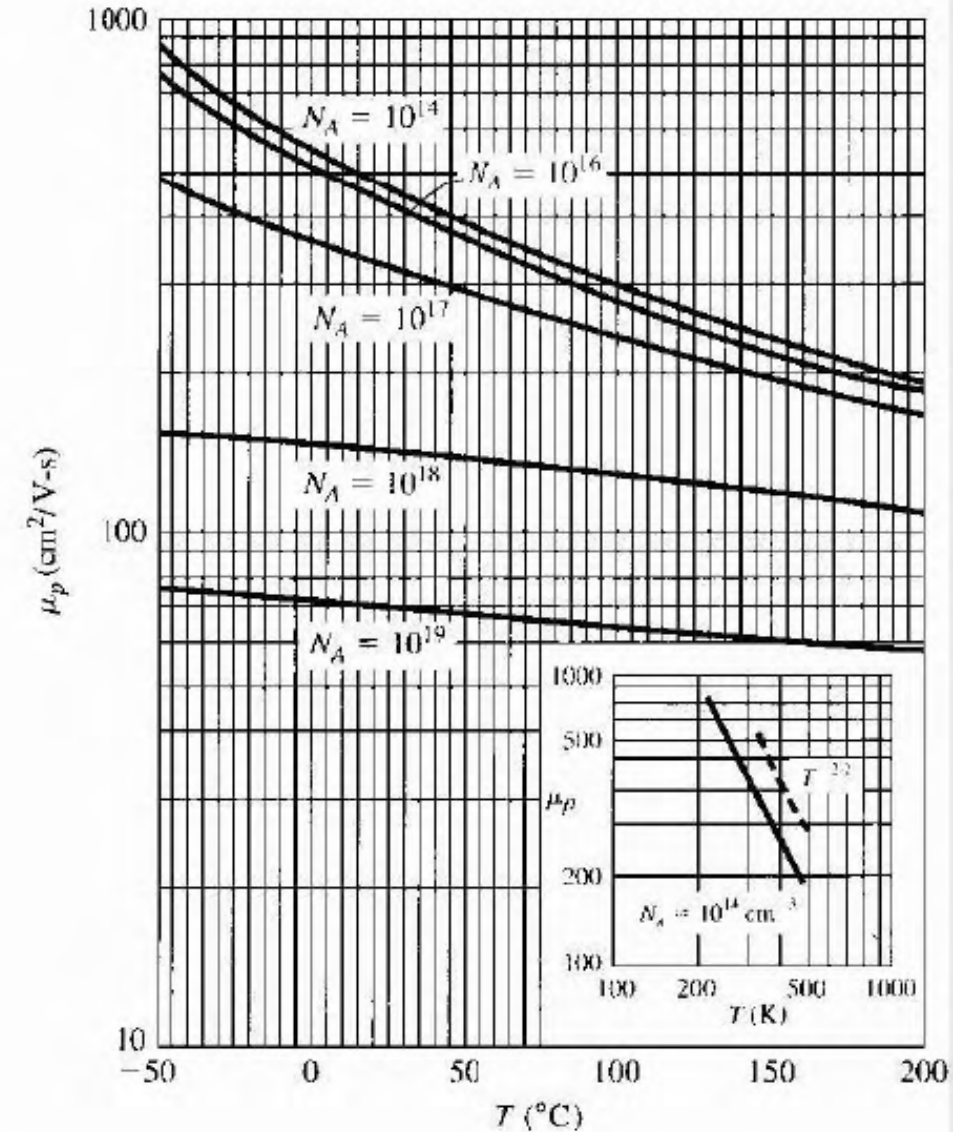
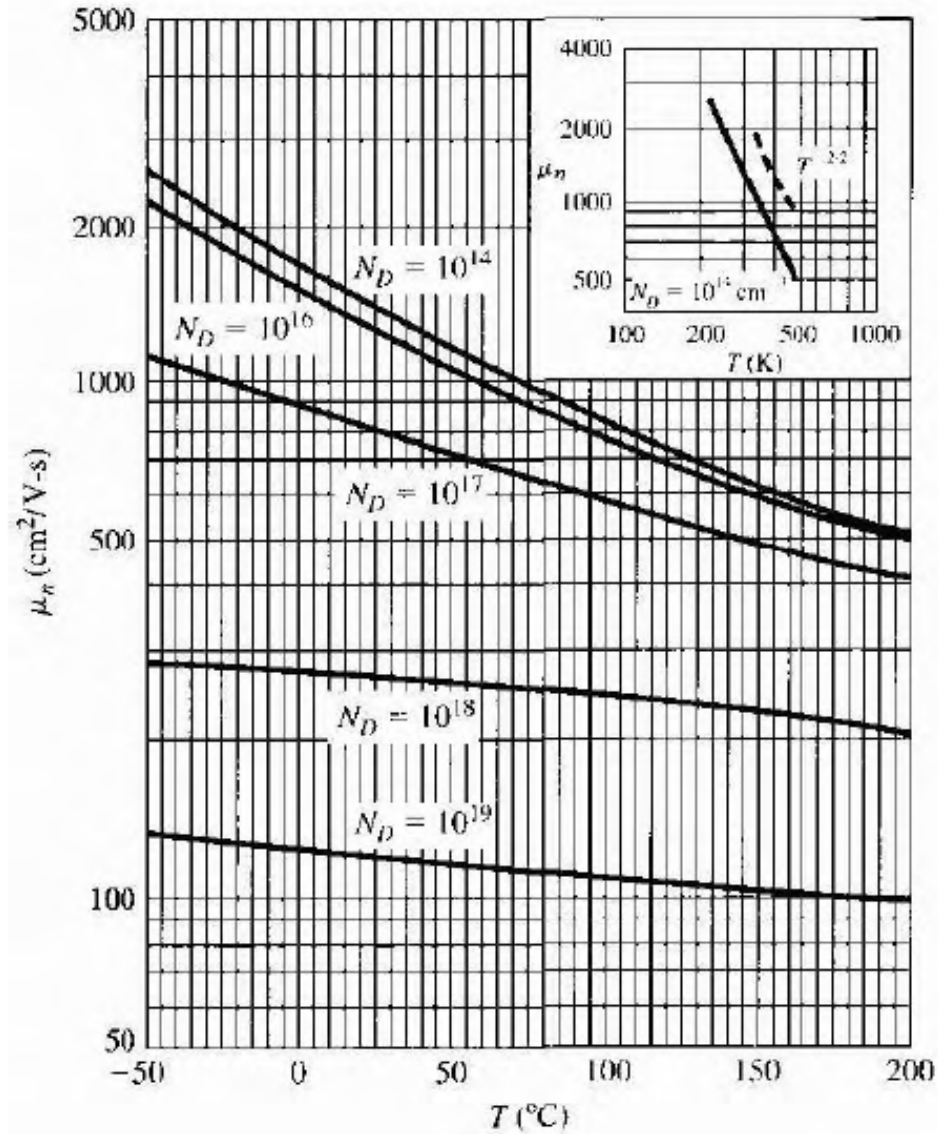
Mode	$D_t K$ ( $10^8$ eV/cm)	$\hbar\omega$ (meV)	Type
TA	0.470	12.1	g-type
LA	0.740	18.5	g-type
LO	10.23	62.0	g-type
TA	0.280	19.0	f-type
LA	1.860	47.4	f-type
TO	1.860	58.6	f-type

Parameters for inelastic phonon scatterings in the Si conduction band



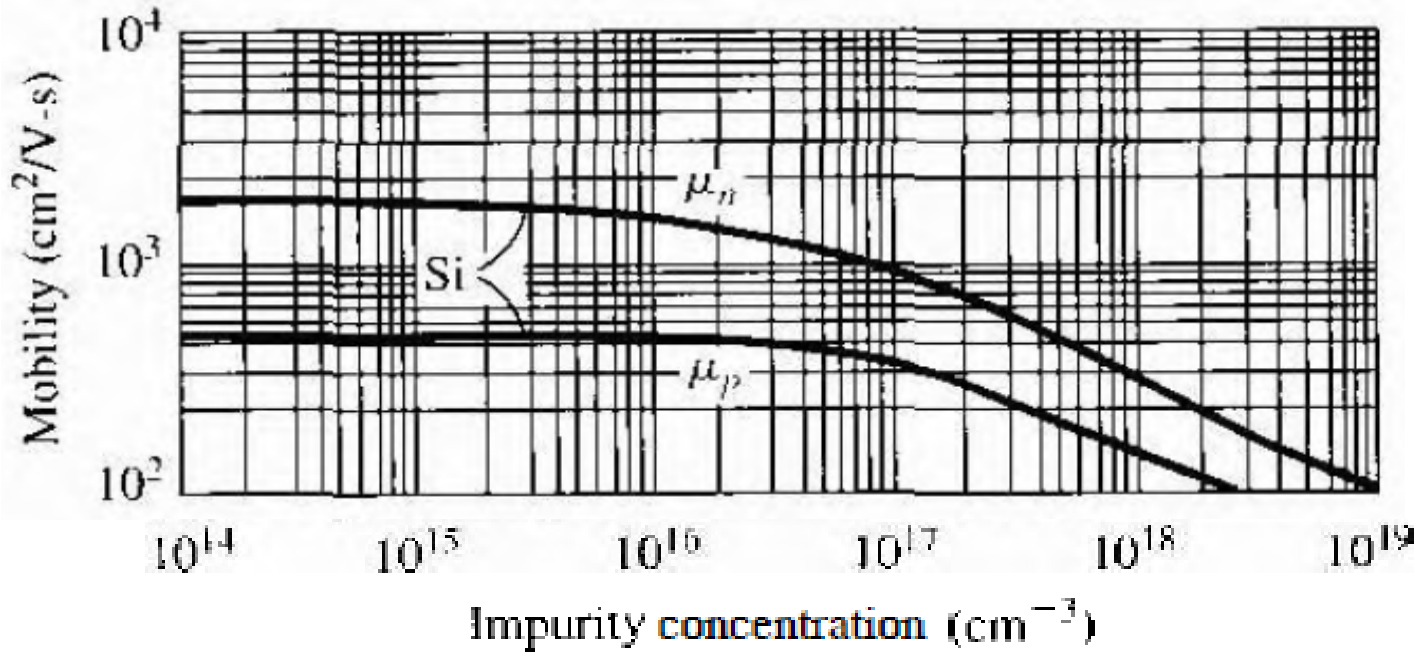
# Temperature & doping

(Neamen's book)



# Impurity concentration

- It is modeled as an elastic scattering process.



(Neamen's book)

- Which one is dominant? Phonon or impurity?

– Matthiessen's rule,  $\frac{1}{\mu} = \frac{1}{\mu_I} + \frac{1}{\mu_L}$

Taur, Eq. (2.27)

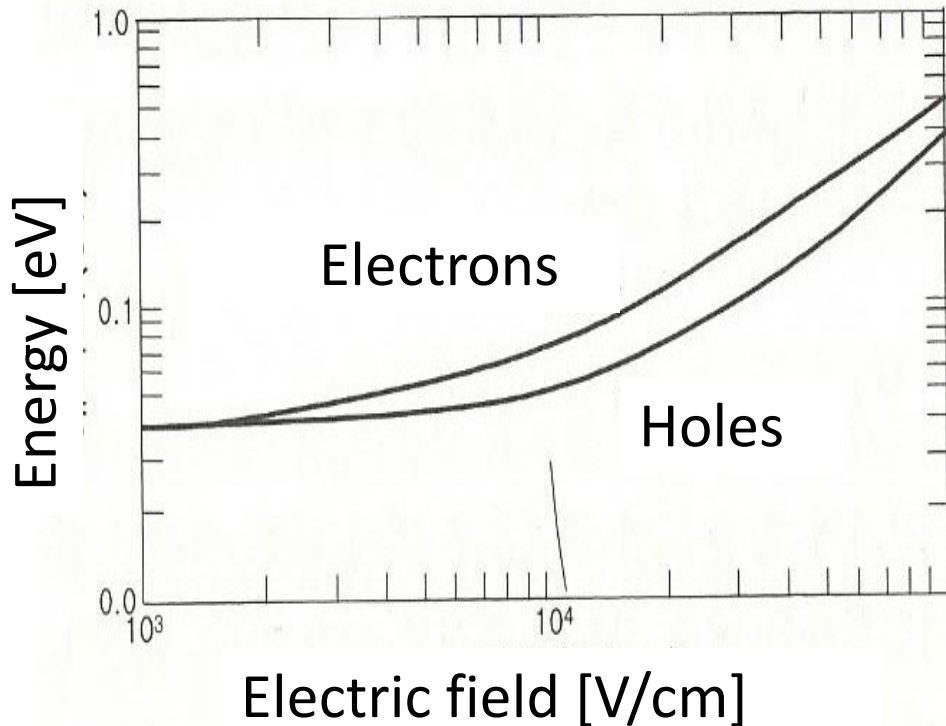
# Matthiessen's rule

- When there are multiple contributions to the mobility,
  - (For example, phonon-limited mobility / impurity-limited mobility)
  - The overall collision rate is given by sum of all contributions.
  - $\frac{1}{\tau_m} = \frac{1}{\tau_{mL}} + \frac{1}{\tau_{mI}} + \dots$
  - (The above relation holds exactly only in the microscopic level.)
  - When recalling  $\mu = \frac{q\tau_m}{m_n}$ , it means  $\frac{1}{\mu_m} = \frac{1}{\mu_{mL}} + \frac{1}{\mu_{mI}} + \dots$
  - It is very useful.



# Hot electron

- Not only velocity, but also energy...
  - Increases when the electric field increases.
  - Increase of energy is a reason of the velocity saturation. *Why?*



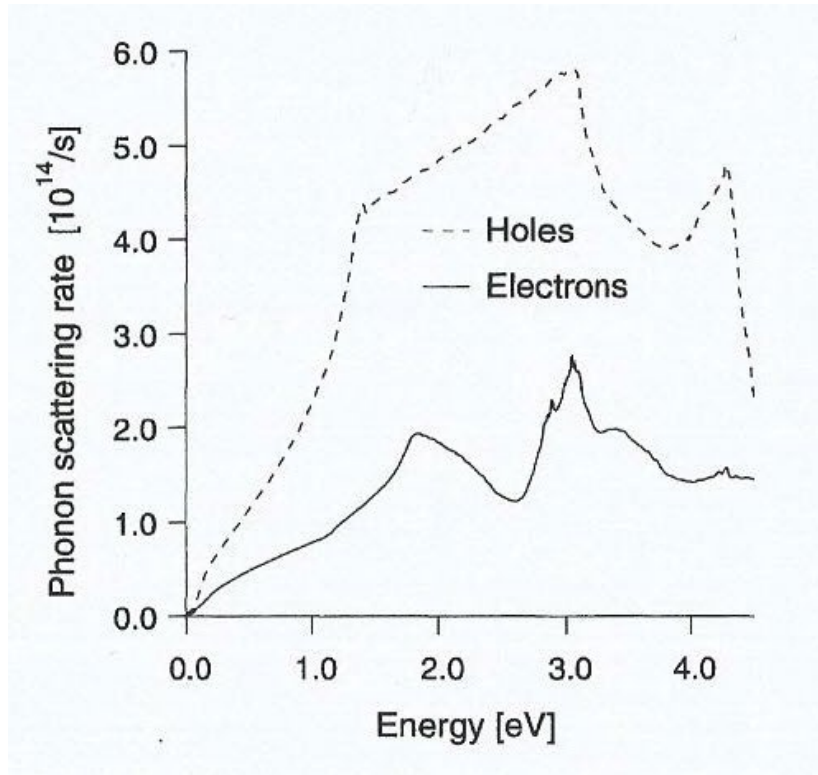
Up to 1 kV/cm, average energy is almost the same with the lattice energy.

Above 10 kV/cm, average energy significantly deviates from the lattice energy.

Average energy of electrons/holes in Si at 300K (Park's book)

# Velocity saturation

- Electron with higher energy
  - Has a higher chance to be scattered by phonons. (Higher DOS)
  - More frequent scattering : Smaller  $\tau_m$

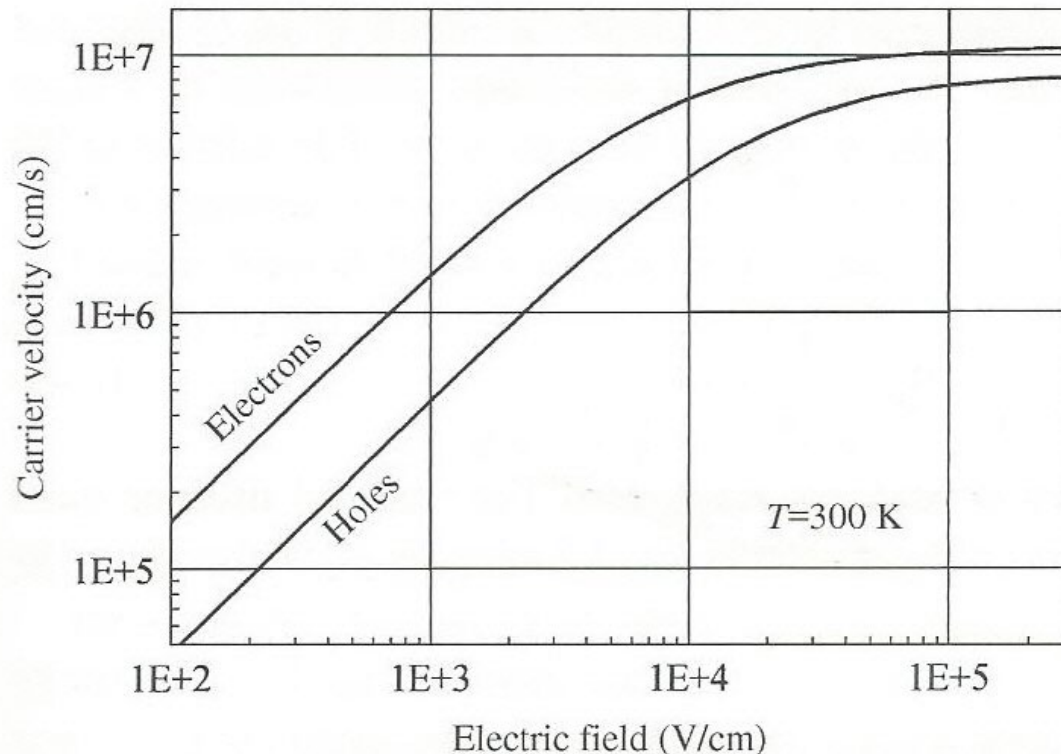


Phonon scattering rate in Si resembles the Density-Of-States.

Phonon scattering rate in Si (Jungemann's book)

# Velocity vs. electric field

- At low electric fields, the linear relationship is valid.
  - At high electric fields, the velocity saturation starts to occur. The saturation velocity of Si is about  $10^7$  (cm/sec).



Velocity-field relationship  
in Si at 300K  
(Taur's book)

# Caughey-Thomas relation

- For silicon,
  - Electron velocity can be approximated by

$$v_n = \frac{v_s}{\left[1 + \left(\frac{E_{on}}{E}\right)^2\right]^{0.5}}$$

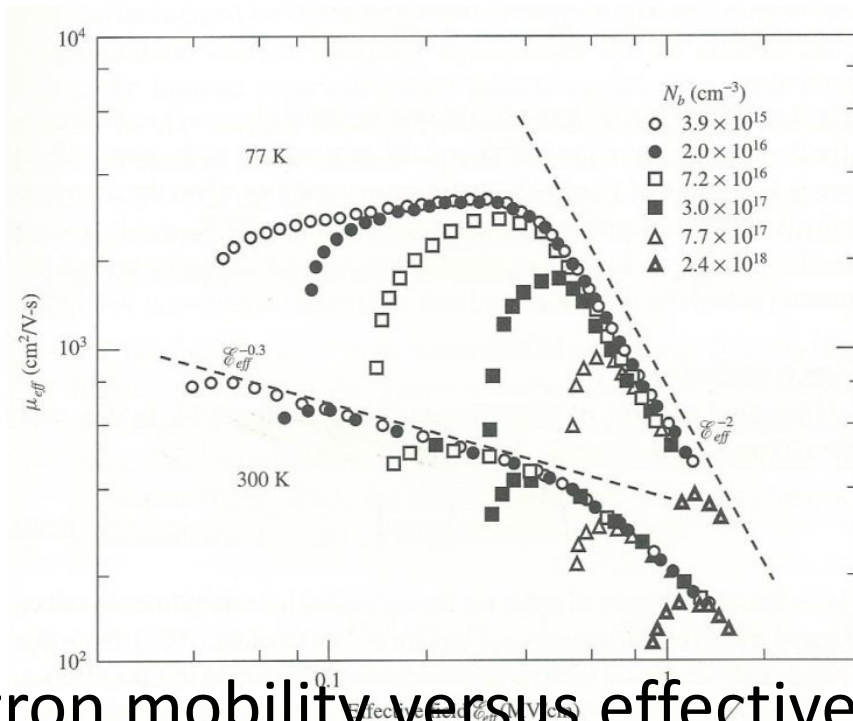
- Hole velocity

$$v_p = \frac{v_s}{\left[1 + \left(\frac{E_{op}}{E}\right)\right]}$$

- Why are they different?

# Other scattering mechanisms

- We have discussed about the bulk mobility.
  - Other scattering mechanisms (alloy scattering & impact ionization)
  - Surface scattering severely reduces the inversion mobility.



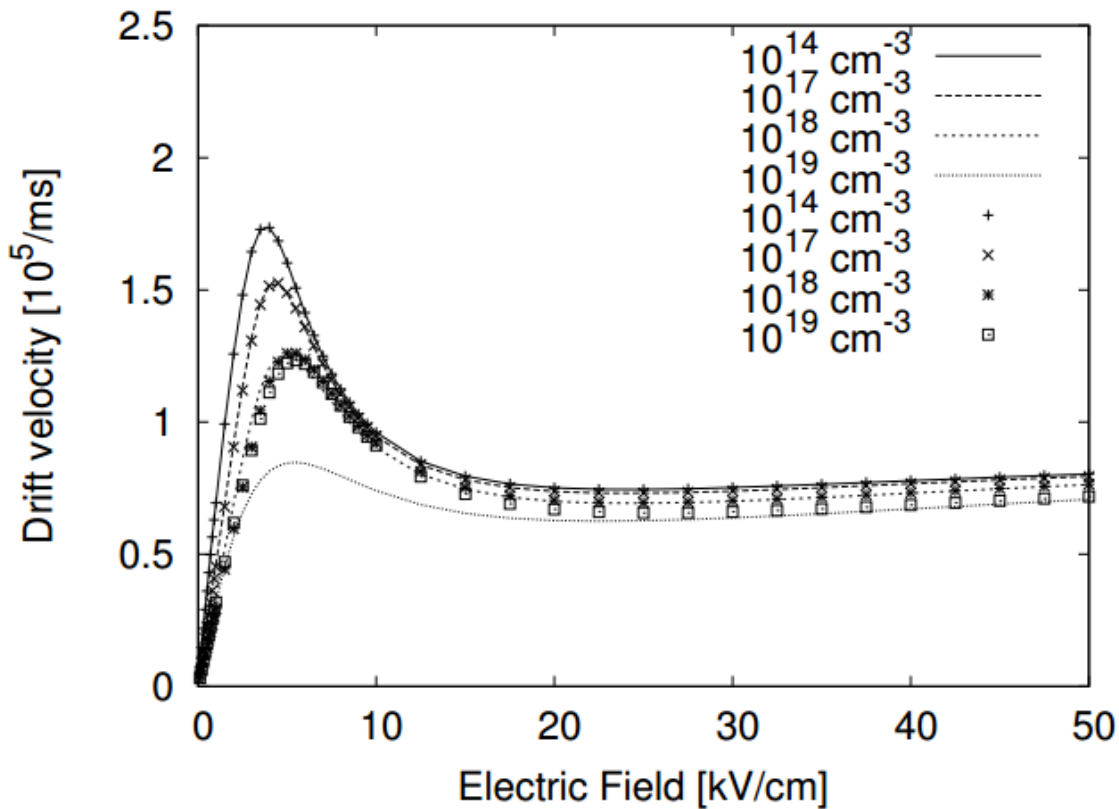
So-called “universal” mobility curve in the Si inversion layer.

Two different contributions are clearly visible.

Electron mobility versus effective field for several doping concentrations (Takagi's paper)

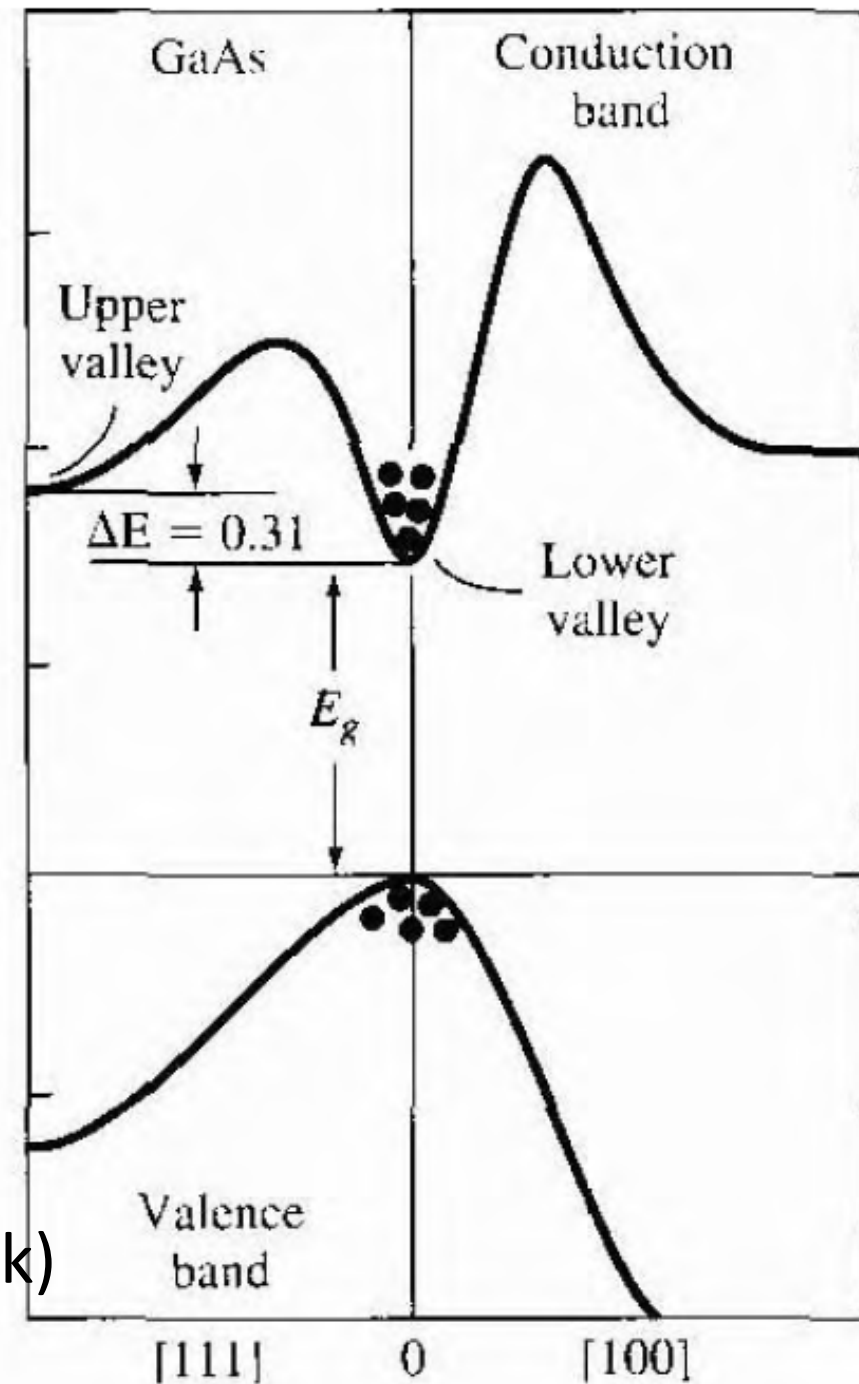
# GaAs case

- Negative differential mobility
  - Its  $L$  valley is heavy.



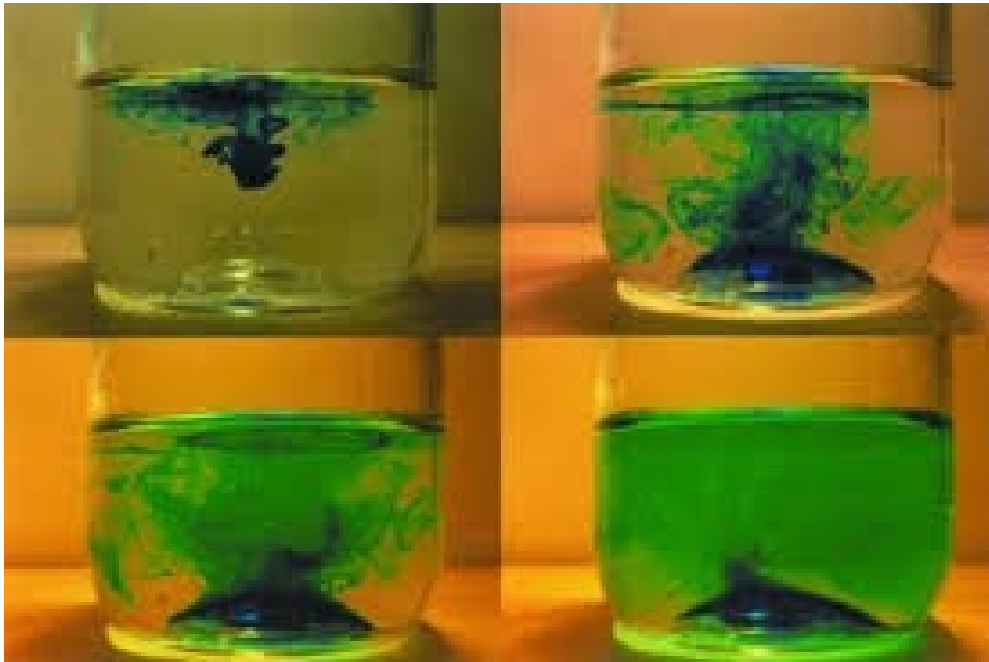
(J. Bieder et al., IWCE 2010)

(Neamen's book)



# Diffusion

- It is not only for charged particles.
  - For example,



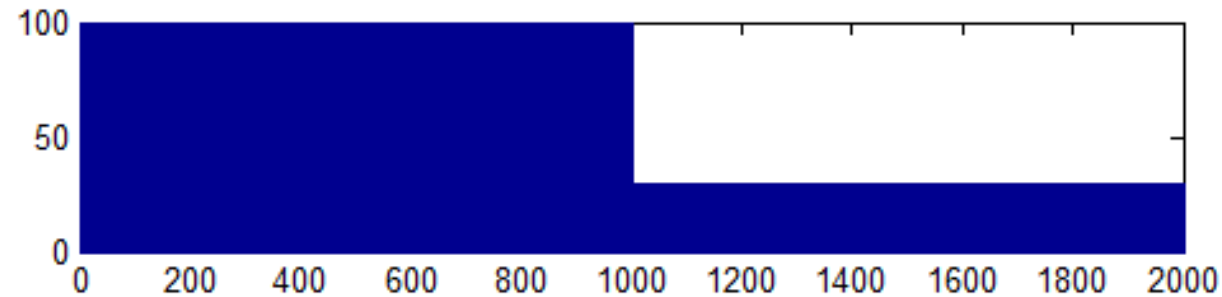
Diffusion of ink  
(Google images)

- Therefore, no polarity is expected.

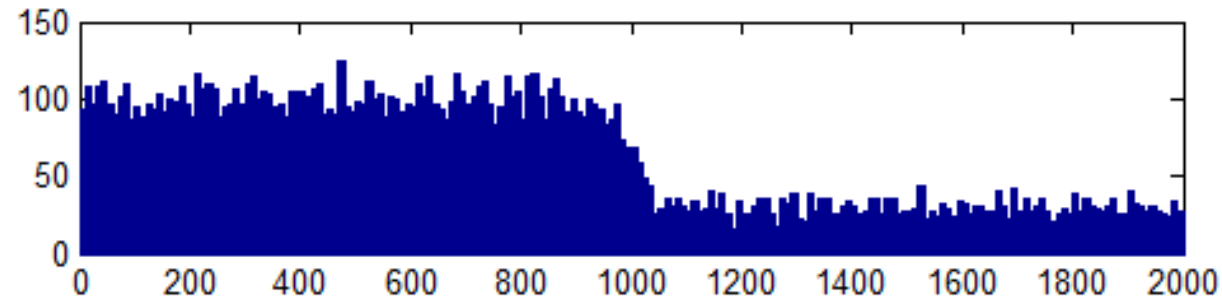
# A simple game, again

- Random motion of balls in a 1D box
  - At each turn, they can move forward (+1) or backward (-1).

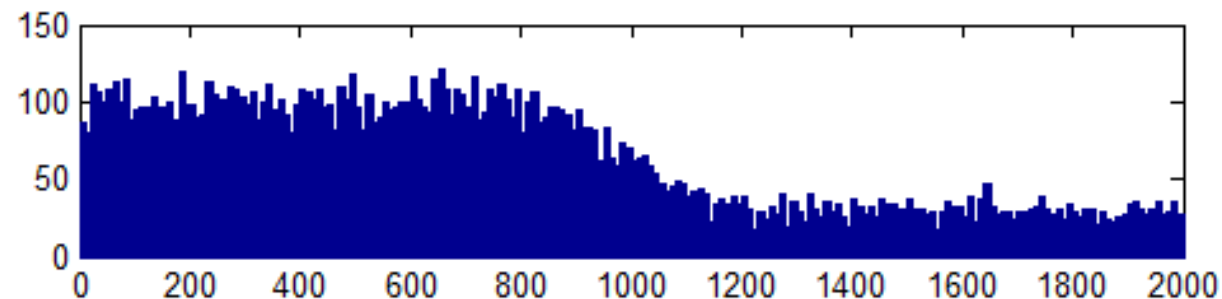
Initial condition



1 k turns



10 k turns





# Equation

- Flux

- The electron flux due to the diffusion mechanism is given by

$$\mathbf{F}_n = -D_n \nabla n$$

where  $D_n$  is the electron diffusion coefficient in the unit of (cm<sup>2</sup>/sec).

- The diffusion current density is

$$\mathbf{J}_{n,diff} = qD_n \nabla n \quad \text{Taur, Eq. (2.36)}$$

- How about the hole?

- The diffusion current density is

$$\mathbf{J}_{p,diff} = -qD_p \nabla p \quad \text{Taur, Eq. (2.37)}$$

# An example

- Taken from Neamen's book
  - Over 1 mm, the electron density varies linearly from  $1 \times 10^{18} \text{ cm}^{-3}$  to  $7 \times 10^{17} \text{ cm}^{-3}$ .
  - The diffusion coefficient is  $D_n = 225 \text{ cm}^2/\text{sec}$ .
  - Calculate the current density.

$$\begin{aligned} J_n &= +qD_n \frac{dn}{dx} \\ &= (1.6 \times 10^{-19} \text{ C})(225 \text{ cm}^2/\text{s}) \left( \frac{1 \times 10^{18} \text{ cm}^{-3} - 7 \times 10^{17} \text{ cm}^{-3}}{0.1 \text{ cm}} \right) \\ &= 108 \text{ A/cm}^2 \end{aligned}$$

# Revisit the total current density.

- Total current density

- Electron current density

$$\mathbf{J}_n = q\mu_n n \mathbf{E} + qD_n \nabla n \quad \text{Taur, Eq. (2.54)}$$

- Hole current density

$$\mathbf{J}_p = q\mu_p p \mathbf{E} - qD_p \nabla p \quad \text{Taur, Eq. (2.55)}$$

- (Time-dependent) displacement current density

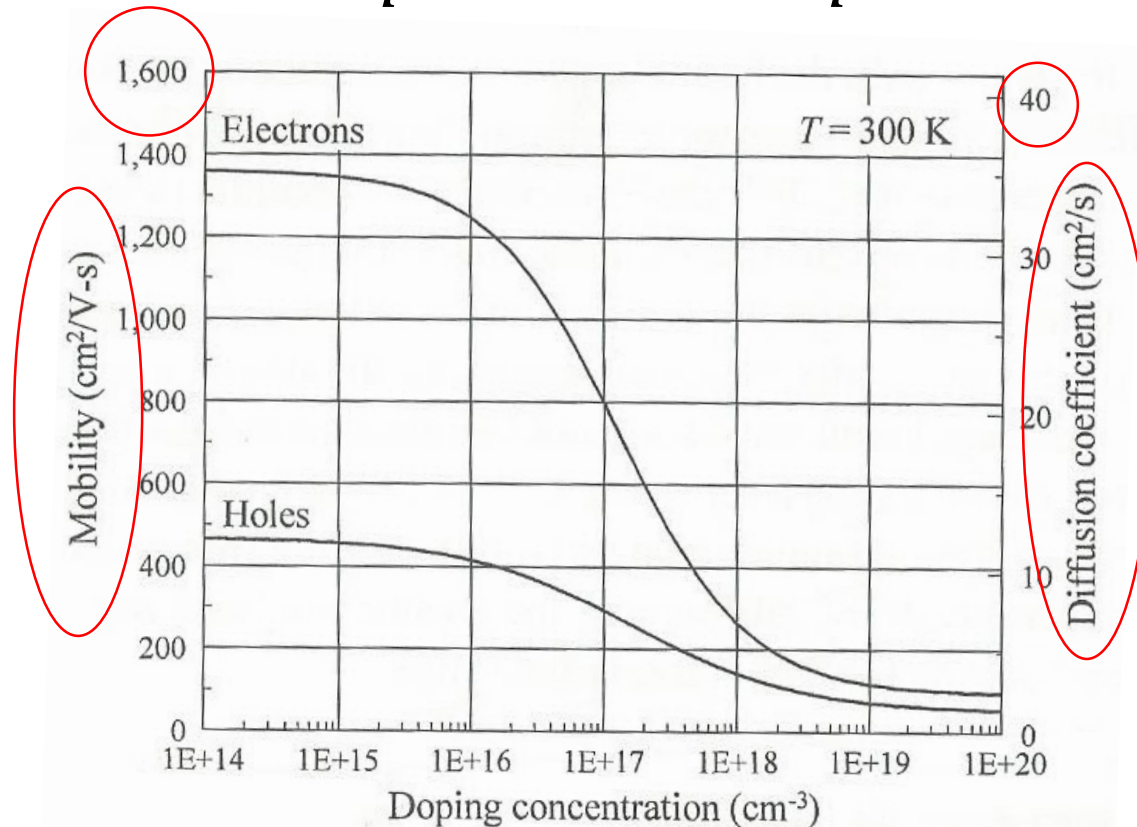
$$\mathbf{J}_{displacement} = \frac{\partial}{\partial t} (\epsilon \mathbf{E})$$

# Einstein relation

- At equilibrium, we have the following relations:

$$D_n = \frac{k_B T}{q} \mu_n, D_p = \frac{k_B T}{q} \mu_p$$

Taur, Eq. (2.38)  
and Eq. (2.39)



(Park's book)

# Thank you!